

Journal of Alloys and Compounds 458 (2008) 189-199



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Phase transformation and morphology of the intermetallic compounds formed at the Sn–9Zn–3.5Ag/Cu interface in aging

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Received 3 November 2006; received in revised form 1 April 2007; accepted 2 April 2007

Available online 6 April 2007

Abstract

The morphology and phase transformation of the intermetallic compounds (IMCs) formed at the Sn–9Zn–3.5Ag/Cu interface in a solid-state reaction have been investigated by X-ray diffraction (XRD), transmission electron microscopy (TEM), electron diffraction (ED), scanning electron microscopy (SEM) and energy dispersive spectrometry (EDS). The monoclinic η' -Cu₆Sn₅ transforms to the hexagonal η -Cu₆Sn₅ and the orthorhombic Cu₅Zn₈ transforms to the body-centered cubic (bcc) γ -Cu₅Zn₈ as aged at 180 °C. The scallop-shaped Cu₆Sn₅ layer is retained after aging at 180 °C for 1000 h. In the solid-state reaction, Ag is repelled from η' -Cu₆Sn₅ and reacts with Sn to form Ag₃Sn, and the Cu₅Zn₈ layer decomposes. Kirkendall voids are not observed at the Sn–9Zn–3.5Ag/Cu interface even after aging at 180 °C for 1000 h. © 2007 Elsevier B.V. All rights reserved.

Keywords: Phase transformation; Intermetallic compound; Sn-9Zn-3.5Ag/Cu; Monoclinic; Hexagonal; Kirkendall voids

1. Introduction

To reduce the pollution caused by Pb, lead-free solders have been utilized to replace gradually the 63Sn–37Pb solder alloy in electronic industry. The morphology, distribution and thickness of the intermetallic compounds (IMCs) formed at the solder alloy/Cu interface affect the solder joint reliability seriously, as reported by Harris and Chagger [1]. Therefore, many researchers have engaged in investigating the interface reactions between solder alloys and Cu substrate or other under bump metallization (UBM) layers [2–5]. η -Cu₆Sn₅ is the most often observed IMC formed at the Sn-base solder/Cu interface and has a hexagonal structure [6–10].

 η -Cu₆Sn₅ is an ordered IMC with the NiAs structure. Westgren and Phrahmen [11] have reported that Cu₆Sn₅ transforms from η to η' at a temperature around 170 °C. η' -Cu₆Sn₅ has a monoclinic structure and is a new superstructure belonging to the NiAs-Ni₂In structure, as reported by Larsson et al. [12] In the previous study [13], a bi-structural Cu₆Sn₅ is found at

the Sn–9Zn–xAg/Cu interface after soldering due to the dissolution of Ag and Zn in η -Cu₆Sn₅. Besides, orthorhombic Cu₅Zn₈ replaces bcc γ -Cu₅Zn₈ forming at the interface when Ag addition in solder alloy is 3.5 wt% [13].

However, the Cu-Sn compound formed Sn-9Zn-3.5Ag/Cu interface after aging at 180 °C for 1000 h is determined as η -Cu₆Sn₅ [14] and no η' -Cu₆Sn₅ is detected. Therefore, the phase transformation of bi-structural Cu₆Sn₅ is proposed to occur in the solid-state reaction. The scallop-shaped and planar IMC layers are the most stable morphology in the reflow and aging processes, respectively, as reported by Tu et al. [15]. The morphology and thickness of the IMCs affect the solder joint reliability [16]. Besides, Yu et al. [2] have shown that the formation of Kirkendall voids after aging at 150 °C for 600 h decreases the adhesion strength of the Sn-9Zn/Cu and Sn-Zn-Al/Cu interfaces. However, Kirkendall voids are not observed at the Sn-9Zn-xAg/Cu interface even after aging at 150 °C for 750 h [17]. Hence, the addition of Ag in the Sn-9Zn solder alloy is beneficial to preventing the formation of Kirkendall voids.

The morphology and phase transformation of the IMCs formed at the Sn-9Zn-3.5Ag/Cu interface in the solid-state reaction have been investigated. The objectives of this study

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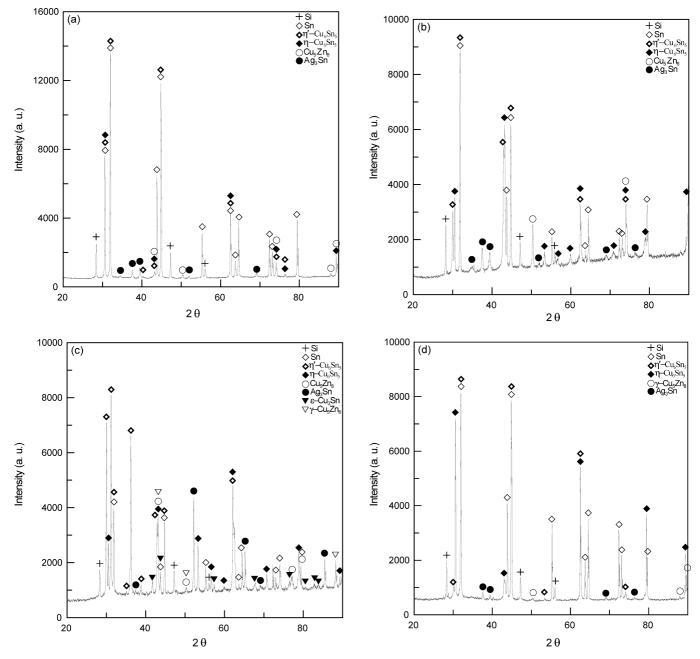


Fig. 1. XRD pattern of the Sn–9Zn–3.5Ag/Cu interface after soldering at $350\,^{\circ}$ C for $30\,^{\circ}$ C and aged at $180\,^{\circ}$ C for $(a)\,^{\circ}$ 0 h, $(b)\,^{\circ}$ 100 h, $(c)\,^{\circ}$ 250 h and $(d)\,^{\circ}$ 400 h.

are: (1) to observe the phase transformation and morphology of the IMCs formed at the Sn–9Zn–3.5Ag/Cu interface in the solid-state reaction, (2) to prevent the formation of Kirkendall voids at the solder alloy/Cu interface as aged at $180\,^{\circ}\text{C}$ with Ag addition and (3) to estimate the adhesion strength of the Sn–9Zn–3.5Ag/Cu interface after aging at $180\,^{\circ}\text{C}$ for various times.

2. Experimental procedure

The Sn–9Zn–3.5Ag solder alloys used in this study were melted with pure metals of Sn, Zn and Ag (purity of 99.9%). They were degreased and deoxidized with 5 vol% HCl and 5 wt% NaOH solutions, respectively. After each step, the metals were rinsed with deionized water, then melted at $600\,^{\circ}\mathrm{C}$ in a stainless steel crucible and stirred to homogenize.

The substrate was an oxygen-free, high conductivity (OFHC) Cu plate and cleaned by the same procedure as mentioned above for pure metals. After cleaning, the Cu substrate was fluxed in a 3.5 wt% DMAHCl solution (3.5 wt% dimethylammonium chloride and ethanol as a solvent) for 10 s and hot-dipped in the molten solder alloy at 350 °C for 10, 20 and 30 s, respectively, to obtain a flat surface, then cooled in air. Afterward, the samples hot-dipped for 30 s were aged at 180 °C for 100, 250, 400, 750 and 1000 h, respectively.

The unreacted solder alloy was removed with sandpapers and an etching solution (40 ml C_2H_5OH+40 ml HCl+10 ml CrO₃+10 ml FeCl₃·6H₂O). XRD (D-MAXIIIB, Rigaku, Japan) was used to determine the structure of intermetallic compounds (IMCs) formed at the Sn–9Zn–3.5Ag/Cu interface at a scanning rate 1° min $^{-1}$ for 2θ from 20 to 90° .

The treated samples were cross-sectioned and mounted in an epoxy, then ground and polished with sandpapers and $0.3\,\mu m$ Al₂O₃ powders, respectively. The polished samples were etched with an etchant (2 vol% HCl+3 vol% HNO₃+95 vol% C₂H₅OH) for 10 s. SEM (JXA-840, JEOL, Japan) was utilized to observe the Sn-9Zn-3.5Ag/Cu interface and EDS (AN10000/85S,

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